

Monolayer Modification of VTe₂ and Its Charge Density Wave

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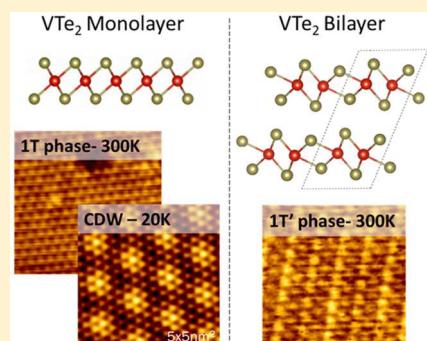
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Supporting Information

ABSTRACT: Interlayer interactions in layered transition metal dichalcogenides are known to be important for describing their electronic properties. Here, we demonstrate that the absence of interlayer coupling in monolayer VTe₂ also causes their structural modification from a distorted 1T' structure in bulk and multilayer samples to a hexagonal 1T structure in the monolayer. X-ray photoemission spectroscopy indicates that this structural transition is associated with electron transfer from the vanadium d bands to the tellurium atoms for the monolayer. This charge transfer may reduce the in-plane d orbital hybridization and thus favor the undistorted 1T structure. Phonon-dispersion calculations show that, in contrast to the 1T' structure, the 1T structure exhibits imaginary phonon modes that lead to a charge density wave (CDW) instability, which is also observed by low-temperature scanning tunneling microscopy as a 4 × 4 periodic lattice distortion. Thus, this work demonstrates a novel CDW material, whose properties are tuned by interlayer interactions.



Modifying the properties of materials by controlling interlayer interactions in van der Waals materials is a promising approach for designing new materials and devices. The excitement for this scheme has been fueled by significant findings in interlayer interaction-dependent properties in transition metal dichalcogenides (TMDCs). Examples of modifications of the properties of materials by tuning of interlayer interactions are (i) the indirect-to-direct band gap transition in the group VI dichalcogenide family when interlayer interactions are removed,^{1–3} (ii) the strong band gap tunability in noble metal dichalcogenides as a function of layers due to interlayer hybridization,^{4–6} (iii) the tunability of the charge density wave transition in TiSe₂^{7,8} and TiTe₂,⁹ and (iv) the recent discovery of a larger Mott insulating state and unique orbital texture in monolayer TaSe₂ compared to multilayers.¹⁰ Here, we investigate for the first time layer-dependent structural modifications in TMDCs on the example of VTe₂. In addition to transforming into a simple 1T structure in the monolayer limit, the lack of interlayer interactions also gives rise to a new charge density wave (CDW) material.

Previous studies of monolayers were primarily performed on the hexagonal, high-symmetry 1T (octahedral) or 2H (trigonal prismatic) polymorphs of TMDCs. In contrast, the group V tellurides form a distorted 1T' structure, known as the ribbon structure,^{11–14} which may be described by a double zigzag row (or ribbon) of coordinated transition metals, in a variation of the possibly better-known single zigzag row 1T' structure (e.g., observed in WTe₂ or β -MoTe₂). Illustrations of these three

related structures can be found below. The commonality of the distorted variations of the 1T structures is that the length of the bond between some transition metals (TM) is reduced as a consequence of interatomic bonding. The basal plane of the ribbon structure can be described as a 3 × 1 reconstruction and the zigzag structure as a 2 × 1 reconstruction of a hexagonal mesh.¹⁵ The distorted 1T structures, either as a ribbon or a zigzag structure, are understood to arise from in-plane metal coordination through d orbital hybridization. The t_{2g} orbitals in the octahedral 1T structure are split by the lattice distortion in the 1T' and 1T'' structures and causes a decrease in the energy of the occupied d_{xy} and d_{xz} bonding orbitals. This is possible if the bonding orbitals are each occupied by two electrons (i.e., a total of four). In the ribbon structure, the bonding orbitals are being shared among three TMs thus requiring an electron count of 4/3 d electrons per TM atom.¹¹ In contrast, a zigzag 1T' structure would share these orbitals between two TMs and thus requiring an electron count of two d electrons per atom for its formation.¹⁶ These arguments suggest that the structure can be controlled by charge donation and withdrawal from the d orbitals. Interlayer interactions in group V ditellurides have been proposed to be important in determining the d orbital occupancy. Theoretical calculations have shown that Te–Te interlayer coupling raises the Te 5p

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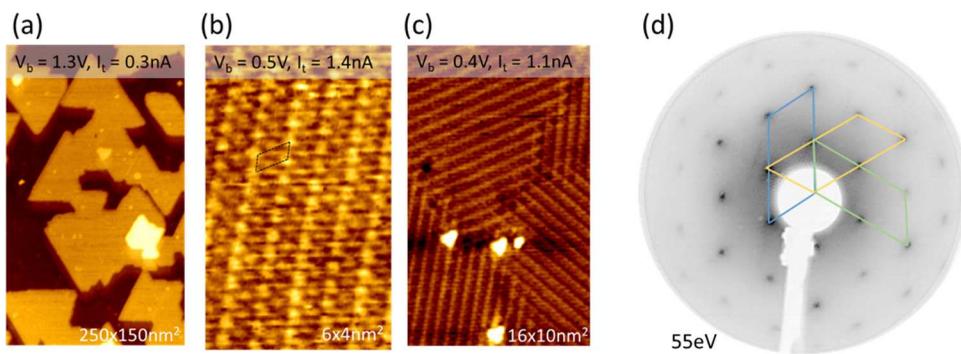


Figure 1. Characterization of multilayer MBE-grown VTe₂. (a) Large scale STM image showing bi- and trilayer terraces. Atomic-resolution images of (b) a 2 × 1 domain and (c) a region showing the coexistence of the three equivalent 2 × 1 domains. The LEED pattern of the sample is shown in panel d with the three reciprocal unit cells of the coexisting 2 × 1 domains indicated.

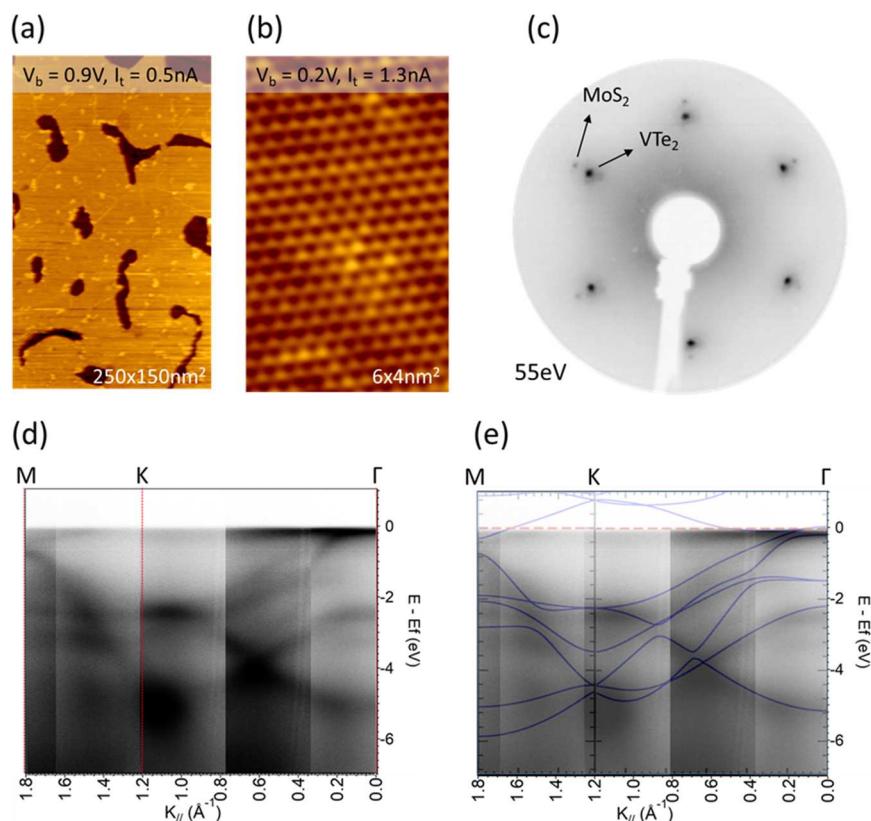


Figure 2. Characterization of monolayer VTe₂. VTe₂ grows in a layer fashion with completion of an almost full monolayer before the second layer nucleates. A large scale STM image of an almost complete monolayer is shown in panel a. Atomic resolution of a simple hexagonal lattice is shown in panel b, while panel c shows the diffraction pattern with both the diffraction spots of the VTe₂ monolayer as well as diffraction spots from the MoS₂ substrate visible. ARPES measurements of a VTe₂ monolayer on the G/SiC substrate are shown in panel d along the Γ –K–M direction. Comparison to DFT band structure calculations for a 1T-VTe₂ monolayer shows close agreement with the measurements, indicating that the film is indeed 1T VTe₂. The DFT band structure and ARPES spectra are overlaid in panel e.

orbitals above the Fermi level and thus causing a charge transfer from the occupied tellurium states to the vanadium 3d orbitals.¹⁷ Consequently, interlayer couplings control the d electron count, and thus, structural control may be asserted by modifying interlayer interactions. Specifically, here we show that the absence of interlayer coupling in monolayers leads to a lifting of the structural distortion and formation of a simple 1T structure in contrast to the 1T' structure for multilayer samples. In this novel 1T form of VTe₂, a 4 × 4 CDW is observed that is unique to the monolayer. The layer dependence of CDW transitions has been a central aspect in

gaining a better understanding in the origins of CDW in TMDCs.^{18–29} Generally, in these studies, a preservation of the CDW properties of the bulk down to the monolayer is observed with only some variations in transition temperatures. The coupling of the CDW to the layer-dependent structural transition sets VTe₂ apart from all of the other TMDC materials and enables the CDW behavior to be restricted to the monolayer limit.

Figure 1 shows scanning tunneling microscope (STM) imaging and low-energy electron diffraction (LEED) of multilayer samples (approximately two to three layers). The

STM image reveals that these multilayer samples expose regions with different numbers of layers given a terraced surface morphology. In higher-resolution images, structural domains are observed with three equivalent rotational domains. Atomic resolution shows that the structure can be described by a 2×1 unit cell with respect to the hexagonal lattice. Three rotational domains with a 2×1 periodicity are also consistent with the LEED pattern, shown in Figure 1d. The formation of a 2×1 periodicity in multilayer samples is different from what would be expected of bulk surfaces of group V tellurides that are reported to exhibit 3×1 structures,¹⁵ consistent with the ribbon structure of these materials. The observed 2×1 structure is consistent with a zigzag $1T'$ structure and thus suggests that the MBE-grown multilayer VTe₂ exhibits a structure different from that of bulk samples. The same structures are observed for films grown on HOPG, graphene/SiC, or MoS₂, so that substrate effects on the structure seem unlikely.

A structural modification occurs if the film thickness is reduced to a single layer. Figure 2 shows STM images of an almost complete monolayer, which grows perfectly without nucleation of second layers. Atomic-resolution images show that the structure is a simple hexagonal structure, consistent with a $1T$ structure. The LEED pattern also exhibits a hexagonal structure. In addition to the LEED spots originating from the VTe₂ monolayer, the diffraction spots from the MoS₂ substrates are also identified. Using the known lattice constant of MoS₂ ($a_{\text{MoS}_2} = 0.316 \text{ nm}$), we measure a lattice constant for VTe₂ (a_{VTe_2}) of 0.36 nm, which is close to the expected lattice constant for bulk VTe₂, indicating that VTe₂ grows unstrained by van der Waals epitaxy on these substrates. To confirm that the structure is $1T$ VTe₂, we performed ARPES on a VTe₂ monolayer grown on a bilayer graphene/SiC substrate along the Γ –K–M direction and compared it to electronic structure calculations by density functional theory (DFT). Although the graphene is single-crystalline, the grown VTe₂ is not in perfect epitaxial relationship, as the LEED pattern shown in Figure S1 shows. Nevertheless, the preferential alignment is sufficient to obtain good quality ARPES data, consistent with other ARPES studies of such van der Waals systems. The measured band structure for VTe₂ is in good agreement with the calculated band structure for $1T$ VTe₂ as shown in Figure 2, thus verifying the crystal structure of the monolayer. Close to the Γ point, a strong V-derived flat band is observed close to the Fermi level that turns above the Fermi level at around the halfway point in the Γ –K direction. Two Te 5p-derived hole pockets are close to the Fermi level at the Γ point and disperse downward in the Γ –K direction. At the M point, the V 3d band forms an electron pocket. In addition to VTe₂ on graphene/SiC, we also performed ARPES of VTe₂/MoS₂ samples, shown in Figure S1. The presence of the MoS₂ substrate makes an identification of the VTe₂ bands more challenging, but the same band structure for VTe₂ can be identified, indicating that we are growing the same $1T$ phase on both substrates.

To explore the structural stability of these phases of VTe₂, we performed phonon-dispersion calculations by DFT using LDA. Panels a and b of Figure 3 show that while the $1T'$ phase is stable, the $1T$ phase exhibits negative frequencies indicative of imaginary phonon modes. Such a phonon instability of the $1T$ phase is suggestive of a CDW transition. The negative modes appear around halfway between Γ –M in the Brillouin

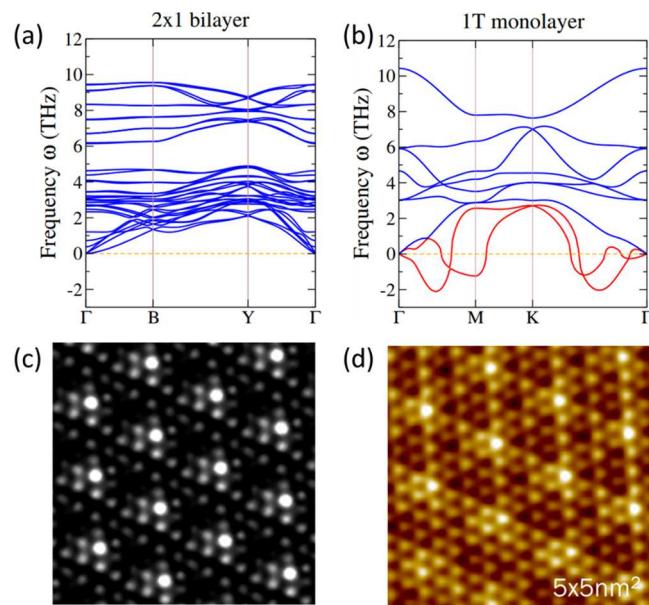


Figure 3. Charge density wave instability in monolayer $1T$ VTe₂. Calculated phonon dispersions are shown for (a) the $1T'$ phase and (b) the $1T$ monolayer. The $1T$ phase exhibits negative frequencies at half-distance between Γ and M indicating a dynamic instability of the $1T$ monolayer with a 4×4 periodicity. The simulated STM image of a 4×4 CDW is shown in panel c, and the experimentally determined 4×4 CDW reconstruction via scanning tunneling microscopy at 20 K is shown in panel d.

zone. Using a zone folding scheme of a 4×4 structure, we can show that all of the imaginary modes fold back onto the Γ point demonstrating a 4×4 CDW unit cell (see Figure S2). The prediction of a CDW instability is confirmed by the STM at 20 K, which shows a clear 4×4 superstructure. To determine the crystal structure of the CDW phase, atoms of a 4×4 superstructure are displaced along the eigenvector of the negative mode mentioned above. After relaxing the displaced structures, we obtain a distorted phase, whose energy is 20 meV/atom lower than that of the perfect $1T$ structure. Calculated phonon dispersion of 4×4 CDW structure indicates that it is dynamically stable (see Figure S3). Using a Tersoff–Hamann approach,³⁰ the STM image of this CDW structure is simulated and compared with the experiment. Good agreement is obtained as is seen from comparing panels c and d of Figure 3. It is noteworthy that we do not find any evidence of a CDW in the STM image for the multilayer $1T'$ samples. This seems to contradict recent reports that observed resistance changes in transport measurements that were attributed to CDW transitions in MBE-grown multilayer VTe₂ samples.³¹ While sample growth is similar, the reported transport measurements were, however, performed on air-exposed samples, which causes uncontrolled adsorption that may change the material property. In this context, it may be noteworthy that our monolayer and few-layer samples are unstable in air. X-ray photoemission spectroscopy (XPS) shows strong oxidation of both V and Te after exposure to air, and good-resolution scanning tunneling microscopy is not possible anymore.

Experimental evidence that the observed layer-dependent structural transition in VTe₂ can be attributed to Te to V charge redistribution as a consequence of interlayer interactions comes from photoemission studies. While several

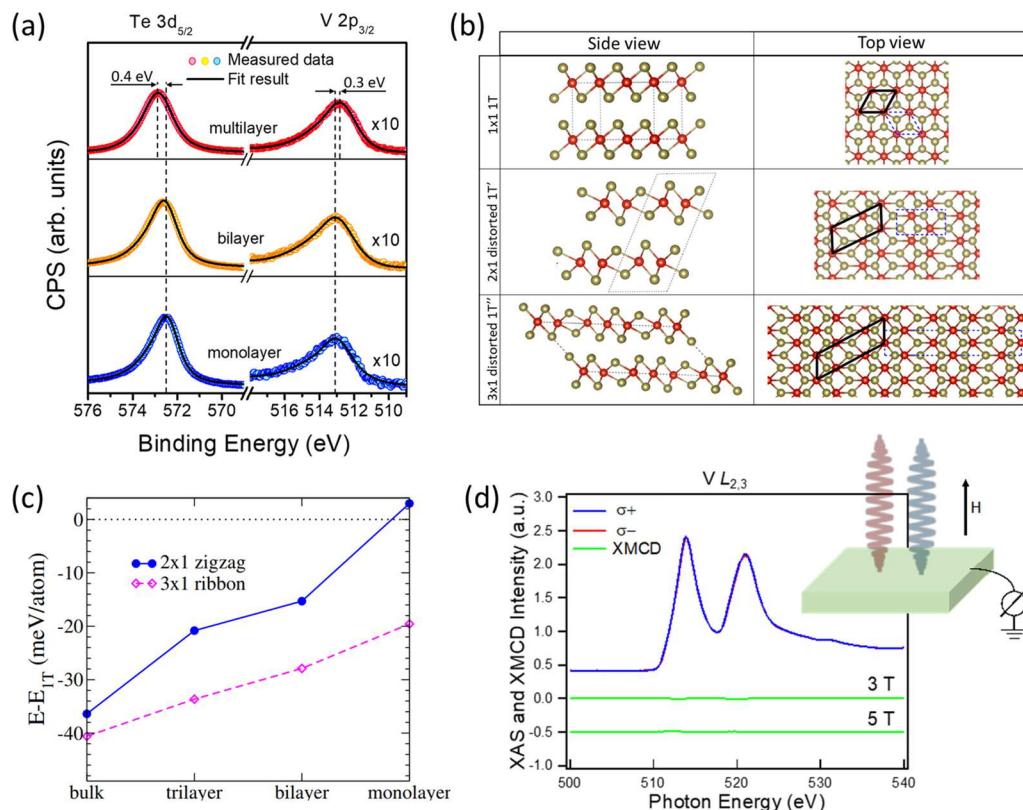


Figure 4. Layer-dependent property variations of VTe₂. The core level shift of Te 3d to a higher binding energy and V 2p to a lower binding energy with an increase in the number of layers is shown in panel a. Ball-and-stick models of the three different structures of VTe₂ are illustrated in panel b, with the top view showing only atoms of a single van der Waals layer. Formation energies for the zigzag 2 × 1 and ribbon 3 × 1 1T' structures relative to the formation energies of the 1T structure are plotted in panel c as a function of layer thickness. With a decrease in layer thickness, the difference in energy between the structures decreases. X-ray absorption (XAS) of the V L_{2,3} edge and the XMCD signal for an applied field of 3 and 5 T are shown in panel d. The absence of any XMCD signal suggests that VTe₂ is nonmagnetic.

effects that occur simultaneously such as splitting of energy levels due to changed crystal fields, changing unit cells, and shifting of energy levels make it challenging to directly compare ARPES data for monolayer and few-layer samples of a 1T and 1T' phase, we instead investigate core level binding energy shifts by XPS. Figure 4a shows the Te 3d_{5/2} and V 2p_{3/2} peak for different layer thicknesses (the full Te 3d and V 2p spectra are shown in Figure S4). The Te peak shifts by ~0.4 eV to a higher binding energy for thicker films compared to the monolayer, while the V 2p peak shifts in the opposite direction by ~0.3 eV to a lower binding energy. This indicates a less negative charge state of Te in the multilayer and thus charge transfer from Te to V. While such charge transfer may explain the 1T structure for the monolayer, the 1T' phase is usually expected for an even higher d electron count than the ribbon structure,¹⁶ i.e., within this charge transfer model, an enhanced charge transfer for multilayers is implied compared to bulk samples. Currently, we cannot conclusively explain why the zigzag 1T' should be favored over the ribbon 1T' structure for multilayers. However, it is interesting to point out that for the related TiTe₂ system a reduced *c* lattice constant compared to bulk values for MBE-grown multilayer samples was recently reported.³² This would suggest stronger interlayer Te–Te contacts and thus enhanced charge transfer. If a similar decrease in the interlayer gap occurs in VTe₂, this could explain the formation of the 1T' structure.

A comparison of the formation energies in DFT calculations also shows that the energy differences among the three

structures become smaller as the film thickness is reduced. Figure 4c shows the formation energy of the two ribbon structures, i.e., zigzag (2 × 1) and ribbon (3 × 1), as a function of the number of layers relative to the 1T structure. Consistent with our observations the 1T structure becomes favored over the 2 × 1 structure only for the monolayer. Similarly, the difference in energy between the 1T form and the 3 × 1 form continues to decrease with a decreasing number of layers, but the 3 × 1 structure remains the lowest-energy configuration among those polymorphs even for the monolayer. It is important to point out, though, that as we mentioned above the 4 × 4 CDW in the monolayer lowers the 1T structure by ~20 meV/atom and thus makes the 1T structure comparable in energy to the 3 × 1 structure. While this could explain the stability of the 1T structure even in 0 K calculations, we may also consider that all samples were grown at ~600 K, at which anharmonicity is significant, and this may favor the 2 × 1 structures for the multilayer and 1T for the monolayer structure. Upon cooling, monolayer 1T experiences spontaneous breaking of symmetry and transforms to the energy-lowering CDW structure. It is noticed that no soft modes at any commensurate *q* point support a transition to the 3 × 1 structure in the monolayer limit. Meanwhile, multilayer 2 × 1 structures are metastable at a local minimum of the potential energy surface, and kinetic barriers may prevent transformation to the lower-energy 3 × 1 structure at low temperatures. In general, the DFT calculations show that the energy differences of the three structures are subtle in the monolayer and this may

allow the structure to be controlled, especially by tuning interlayer interactions in van der Waals heterostructures.

Magnetic ordering in monolayer vanadium dichalcogenides has been a contentious topic,^{25–28,33,34} and VTe₂ has also been suggested from DFT to exhibit ferromagnetic ordering in the monolayer limit.^{35,36} We determine the absence of magnetic ordering of our VTe₂ samples by X-ray magnetic circular dichroism (XMCD). Typical XAS and XMCD spectra of VTe₂, normalized to the incident beam intensity, are presented in Figure 4d. The XAS spectra of V for both left- and right-circularly polarized X-rays show a wide line at each spin-orbit split core level without prominent multiplet structure. This is proof that the sample has been well protected from oxidation by the Te-capping layer. No appreciable XMCD was detected in applied magnetic fields of either 3 or 5 T, suggesting no intrinsic magnetism of the VTe₂ monolayer.

In conclusion, a new CDW material in the form of 1T VTe₂ has been discovered. The 1T phase of VTe₂ is stable only in the monolayer limit, suggesting that interlayer interactions in multilayer and bulk VTe₂ are responsible for the distortion of the 1T structure into 1T' phases. This demonstrates that tuning of the interlayer interactions, in, for example, van der Waals heterostructures, can be used not only to control electronic properties but also to induce structural variations and tune many-body physics phenomena like CDW transitions.

METHODS

To study the layer-dependent properties in VTe₂, we grew films by molecular beam epitaxy (MBE) on different van der Waals substrates, namely, graphite/HOPG, bilayer graphene/6H-SiC, and MoS₂ single crystals. The substrates are cleaved in air and outgassed in UHV at 300 °C for 2 h, prior to growth. V is evaporated from a mini e-beam evaporator, while Te is co-deposited from a K-cell. The Te flux exceeds the V flux by a factor of ~10. The optimum growth temperature was established to be ~300 °C with a growth rate of one monolayer (ML) in ~16 min. The grown samples were transferred *in situ* from the growth chamber to a surface analysis chamber equipped with a Scienta R3000 hemispherical analyzer for photoemission spectroscopy, LEED, and a room-temperature STM. For angle-resolved photoemission, a refocused VUV He-discharge lamp using the He-I line was used and the measurements were taken with the sample at room temperature. X-ray photoemission was conducted using a dual-anode X-ray source, and the spectra shown here used nonmonochromatized Al K α radiation. Additional characterization was performed in a variable-temperature (VT) STM with a lowest temperature of 20 K. For these studies, the sample was transferred in a vacuum suitcase from the growth chamber to the VT STM. In addition, magnetic characterization by XMCD of the V L_{2,3} absorption edges was performed at beamline I10 of the Diamond Light Source in the United Kingdom. For these measurements, the MBE-grown VTe₂ samples were capped with an ~10 nm Te capping layer and shipped in an inert gas atmosphere to the United Kingdom. XMCD measurements were obtained by using ~100% circularly polarized X-rays with normal incidence with respect to the sample plane and parallel to the applied magnetic field, that is, in Faraday geometry. XAS measurements were carried out at 300 K using total electron yield (TEY) detection. XMCD was obtained by taking the difference of the XAS spectra, $\sigma_- - \sigma_+$, obtained by flipping the X-ray

helicity at a fixed magnetic field up to 50 kOe. DFT for geometry optimization and electronic structure calculations were performed using the Vienna Ab-initio Simulation Package (VASP).⁴¹ Projector augmented wave (PAW)⁴² pseudopotentials and a local density approximation (LDA) functional with a 500 eV plane wave energy cutoff were used. Brillouin zones of 1T, 2 × 1, and 3 × 1 structures were sampled with dense k -point 11 × 11, 5 × 11, and 3 × 9 grids, respectively. Crystal structure optimization was performed with a force tolerance of 0.001 eV/Å.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: [10.1021/acs.jpclett.9b01949](https://doi.org/10.1021/acs.jpclett.9b01949).

Comparison of LEED and ARPES of monolayer VTe₂ on different van der Waals substrates, zone folding and phonon dispersion of 4 × 4 CDW in monolayer VTe₂, and XPS spectra of Te 3d and V 2p as a function of the number of layers ([PDF](#))

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Author Contributions

P.M.C. and K.L. grew the samples and characterized them via RT-STM, XPS, and ARPES experiments. K.N.C. and I.I.O. performed DFT calculations. J.L. performed LT-STM studies. W.N. and W.L. performed synchrotron XAS and XMCD studies. M.B. directed the research and wrote the manuscript. All authors contributed to the analysis, discussion, and presentation of the data.

Notes

The authors declare no competing financial interest.

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■ NOTE ADDED IN PROOF

During final submission of the manuscript, we became aware of manuscripts^{37–40} that are consistent with our observation of a 4×4 CDW in monolayer VTe₂.